Electrically detected magnetic resonance in a W-band microwave cavity

V. Lang,^{1,a),b)} C. C. Lo,^{2,a)} R. E. George,³ S. A. Lyon,⁴ J. Bokor,² T. Schenkel,⁵ A. Ardavan,³ and J. J. L. Morton^{1,3}

 ¹Department of Materials, University of Oxford, Oxford OX1 3PH, United Kingdom
²Department of Electrical Engineering and Computer Sciences, University of California, Berkeley, California 94720, USA
³CAESR, Clarendon Laboratory, Department of Physics, University of Oxford, Oxford OX1 3PU, United Kingdom
⁴Department of Electrical Engineering, Princeton University, Princeton New Jersey 08544, USA
⁵Accelerator and Fusion Research Division, Lawrence Berkeley National Laboratory, Berkeley, California 94720, USA

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We describe a low-temperature sample probe for the electrical detection of magnetic resonance in a resonant W-band (94 GHz) microwave cavity. The advantages of this approach are demonstrated by experiments on silicon field-effect transistors. A comparison with conventional low-frequency measurements at X-band (9.7 GHz) on the same devices reveals an up to 100-fold enhancement of the signal intensity. In addition, resonance lines that are unresolved at X-band are clearly separated in the W-band measurements. Electrically detected magnetic resonance at high magnetic fields and high microwave frequencies is therefore a very sensitive technique for studying electron spins with an enhanced spectral resolution and sensitivity. © 2011 American Institute of Physics. [doi:10.1063/1.3557395]

Electron paramagnetic resonance¹ (EPR) is an important spectroscopic technique used to identify and study electron spins in various material systems. Most conventional EPR measurements are carried out at a microwave frequency of around 9.7 GHz (X-band). For material systems with an electron gyromagnetic ratio of $g \sim 2$, this corresponds to a resonant field of approximately 0.35 T and a Zeeman splitting of 40 μ eV. Hence, the sensitivity of conventional X-band EPR is limited and typically requires at least 10¹⁰ paramagnetic sites in the sample.² In order to enhance the detection sensitivity, EPR has been combined with optical^{3,4} and electrical detection schemes.⁵⁻⁸ Electrically detected magnetic resonance (EDMR), in which the EPR induced change in spin population is detected through the change in conductivity of the sample,^{12,13} has been reported to provide a more than 10⁶ times higher sensitivity than conventional EPR.9-11

Higher EPR sensitivities and spectral resolutions can be achieved by using higher magnetic fields and higher microwave frequencies, as the EPR signal intensity scales with the spin polarization, and the *g*-factor resolution with the operating frequency, linearly.¹⁴ High sensitivities and high spectral resolutions are both very desirable and of great importance for the characterization of material systems, such as defect identifications in solar cells, and the emerging fields of spintronics and quantum computation, as they offer the opportunity to selectively address and study single electron spins. Furthermore, a comparison of the same device at different magnetic fields provides information on the microscopic mechanism that gives rise to the EDMR signal.

So far, high-field EDMR has been carried out at 8.50 T on Si:P (Refs. 15-17) with a multimode (Fabry-Pérot) cavity only, which requires comparatively long pulse duration times of the order of a few hundred nanoseconds for a π -pulse.^{15,16} The sensitivity in those experiments was limited to $\sim 5 \times 10^7$ spins in the sample.¹⁵ The implementation of fast microwave pulses with large excitation bandwidths for the coherent control of electron spins via pulsed-EDMR (Ref. 18) thus remains technologically challenging and has not been achieved at high magnetic fields so far. Single-mode cavities on the other hand offer fast microwave pulses ($\pi \sim 32$ ns in our system) to achieve large excitation bandwidths. In addition, the distribution of the microwave field in single-mode cavities is well defined. Hence, the sample can be placed at the position where the magnetic field component is maximal and the electrical field component minimal, which is much more difficult to achieve in multimode resonators and essential for the minimization of microwave-induced rectification noise. This work combines the advantages of single-mode cavities with the enhanced sensitivity of an electrical readout and the enhanced spectral resolution at high microwave frequencies and high magnetic fields. In particular, we describe our approach to perform EDMR in a single-mode microwave cavity at 3.36 T and 94 GHz (W-band).

Since the half-wavelength of free space microwaves at 94 GHz amounts to 1.6 mm, the size of a W-band microwave resonator typically lies within the range of a millimetre and EDMR experiments require (i) a small sample size, (ii) an optimized geometry and metallization for reduced microwave absorption, and (iii) an accurate sample placement inside the resonator. The sample probe wiring has to enable the detection of small voltages and currents with a low noise level. Our low-temperature sample probe was designed for use in a commercial Bruker Teraflex EN 600-1021H TE₀₁₁ mode pulsed

^{a)}These authors contributed equally to this work.

b)Author to whom correspondence should be addressed. Electronic mail: volker.lang@materials.ox.ac.uk.



FIG. 1. (Color online). (a) Schematic drawing showing the sample placement inside the W-band EPR microwave cavity. Black arrows indicate the orientations of the static magnetic Zeeman and microwave fields, B_0 and B_1 , respectively. (b) shows a series of optical images of a sample (top-left) being inserted into the brass collet (bottom) used to guide the device into the cylindrical microwave cavity. Aluminum wirebonds connect the device with a printed circuit board and are visible through the window in the sample collet (top-right).

electron nuclear double resonance resonator, which has an inner diameter of 0.87 mm and a length of 1-1.6 mm depending on the particular tuning condition. The sample placement inside the W-band microwave cavity as well as the most important dimensions are shown in Fig. 1(a) schematically. The sample collet developed for this work facilitates a safe and accurate sample placement inside the microwave cavity and is shown in Fig. 1(b). It consists of a brass tip, which allows accurate centering of the device inside the cylindrical cavity along the symmetry axis. A micrometer screw equipped with a vacuum seal at the probe head is used to withdraw the fragile sample within the collet in order to protect it while the probe is inserted into the cryostat. Once the sample probe is aligned against the resonator window, the micromanipulator can be used to push the sample out of the collet and to position it inside the resonator with $\sim 100 \,\mu m$ precision. Withdrawing the sample from the cavity back into the collet protects the device during the extraction of the sample probe from the cryostat once the experiment is finished. We have also machined a sample collet out of G1040 glass epoxy, with which the same sample can be measured in a conventional X-band system without disturbing the microwave field and without changing the sample probe. The sample is connected to a double-sided printed circuit (PC) board via aluminium wirebonds, which are visible through a window in the brass tip as shown in the top-right image of Fig. 1(b). This arrangement allows us to contact the active area of the device by metallic layers with a thickness of $\sim 0.1 \,\mu\text{m}$ below the skin depth of microwaves at 94 GHz (Ref. 14) and to minimize the disturbance of the microwave field in the resonator. The PC board is equipped with a six-pin Omnetics PZN-06-DD

miniature connector at its top end, which is connected to stainless steel coaxial cables (LakeShore CC-SS).¹⁹ The coaxial lines terminate in female vacuum-tight SMA connectors at the probe head. From the capacitance of the coaxial cables used in the probe stick (\sim 200 pF), we expect a measurement bandwidth of 10 kHz to be possible with the current setup for a sample resistance of \sim 100 kΩ.

We have used this sample probe to detect the EDMR effect of conduction band electrons in silicon-based n-type accumulation-mode field-effect transistors (aFETs). The results presented in this work are representative for all measurements. The device has a triple-gate geometry for enhancing the spin polarization of the injected conduction electrons, but for the purpose of this study, all three gates are biased together and the whole device is considered as a simple three-terminal aFET. The device has a total channel length of 160 μ m and width 40 μ m and is fabricated on a silicon substrate with a 1 μ m thick isotopically purified ²⁸Si epitaxial layer with $3 \times 10^{16} \text{ cm}^{-3}$ phosphorus doping. In addition, the channel was implanted with arsenic (75As) donors at 50 keV and a dose of 4×10^{11} cm⁻². From secondary ion mass spectroscopy we estimate approximately 6×10^5 arsenic and $4 \times$ 10⁶ phosphorus donors residing within 10 nm of the oxide interface of the device channel. The device layout is optimized for microwave cavity-based EDMR measurements with minimal metal thicknesses. All samples were diced into small chips of $15.0 \times 0.5 \times 0.3 \text{ mm}^3$ in size and connected to the sample probe with the sample arrangements described above.

W-band EDMR was performed with a Bruker ElexSys E680 W-band EPR spectrometer and an Oxford Instruments CF-1200 helium-gas flow cryostat in combination with an Oxford Instruments ITC-503S temperature controller. The DC magnetic field $B_0 \sim 3.36$ T was generated with a Bruker EPR 6T SC superconducting magnet. X-band EDMR measurements were carried out on the same device with a Bruker ElexSys E680 X-band EPR spectrometer and an Oxford Instruments CF-935 helium-gas flow cryostat. The microwave excitation was applied using a Bruker Flexline ER 4118X-MD5-W1 X-band dielectric ring resonator operating at a DC magnetic field $B_0 \sim 0.35$ T. All measurements presented in this work were carried out at T = 5 K, and the Zeeman field was aligned in the plane of the 2DEG, perpendicular to the direction of current flow. Magnetic field modulation was used at both microwave frequencies to enhance the signal-to-noise ratio, which results in the EDMR signal appearing as the first derivative of the sample resistivity with respect to magnetic field, i.e., $\partial (\Delta \rho / \rho_0) / \partial B$. The circuitry used to provide isolation from mains noise and to detect the resonant change of the sample resistivity is shown in Fig. 2. Battery powered variable resistor networks were used to apply a constant current to the sample and to bias it with a constant gate voltage, typically 300 mV. The resonant change of the source-drain voltage across the aFET was detected via a battery powered variable gain low-noise voltage amplifier (Femto DLPVA-100-F-D) and a bandpass filter (Princeton Applied Research 5210 lock-in amplifier) tuned to the modulation frequency of 5.02 kHz. A voltage follower (OPA TL074CN) facilitated the impedance matching between the whole circuitry and the software driven lock-in amplifier of the Bruker ElexSys E680



FIG. 2. (Color online). Circuit diagram of the electrical measurement setup used to detect EDMR on silicon field-effect transistors. Please refer to the text for further details.

unit, which was used to demodulate and detect the EDMR signal. We used a field modulation amplitude of 0.2 mT throughout, calibrated at both W- and X-band.

The W- and X-band EDMR spectra of a typical aFET are shown in Fig. 3. In both spectra, the resonance line with the largest amplitude has a g-factor of g = 1.9999 and corresponds to the two-dimensional electron gas (2DEG).^{20,21} The two satellite peaks of the ³¹P donors are evidenced by the expected phosphorus hyperfine splitting of 4.2 mT.²² Four weaker resonances are separated by 7.1 mT from each other, which corresponds to the four different nuclear spin projections of ⁷⁵As donors.²³ All donor lines are centered around g = 1.9987, and hence the low-field hyperfine-split resonance of the ³¹P donors is superimposed with the large 2DEG resonance in W-band as the difference in g-factors corresponds to -2.1 mT at that frequency. Exchange-coupled donor pairs and clusters give rise to a resonance signal $S_i S_j$ at the center of the hyperfine-split lines,²⁴ which overlaps with the 2DEG resonance at X-band, and is well separated from the large 2DEG signal at W-band. This demonstrates the superior spectral resolution in W- over X-band EDMR measurements.



FIG. 3. (Color online). Typical W- (top) and X-band EDMR spectra (bottom). The main resonance is due to the 2DEG, the weaker lines are due to ³¹P and ⁷⁵As donors, respectively. The resonance line associated with exchangecoupled donor pairs and clusters $S_i S_j$ is well separated from the 2DEG at Wband only. Tenfold zooms are shown for the exchange-coupled donor pairs and ⁷⁵As lines and offset for clarity.



FIG. 4. (Color online). W-band power dependence of the EDMR signal intensity of the 2DEG (\Box), phosphorus (\bigcirc), and arsenic (\triangle) line on a semilogarithmic scale. All three lines are well saturated for a microwave power larger than ~5 mW. Solid lines are guides to the eye for clarity only.

Another difference between the W- and X-band spectra shown in Fig. 3 concerns the EDMR signal intensities. For a better comparison we calculated the EDMR signal intensity by integration of $\partial (\Delta \rho / \rho_0) / \partial B$ with respect to magnetic field and thus define it as the amplitude of the absorption line. This analysis reveals a \sim 100-fold increase in signal intensity for the 2DEG and a \sim 20-fold increase for the ³¹P and ⁷⁵As donor resonances. Details of this scaling as well as the particular EDMR mechanisms giving rise to these signals are discussed elsewhere.²⁵ The superior signal amplitudes at W- over X-band improve the signal-to-noise ratio S/N from S/N = 4:1 at X- to 8:1 at W-band for a single scan. The number of arsenic spins detected in our experiments is smaller than $\sim 10^6$, and from the S/N in our W-band measurements, a sensitivity of 2×10^4 per hyperfine line should be achievable in a single scan. This is very encouraging, particularly since high-field EDMR has not been demonstrated with fewer than $\sim 10^9$ spins and a sensitivity better than 5 \times 10⁷ so far.¹⁵

Figure 4 shows the microwave power dependence of the EDMR signal intensity of the 2DEG, phosphorus, and arsenic line. It reveals a typical saturation behavior for all three resonance lines associated with the 2DEG, phosphorus, and arsenic spin system, respectively. The signal intensity of each line reaches its maximum value at around ~ 5 mW, and the three spin systems are well saturated above this value. Power saturation only occurs if the incident microwave power is high enough to populate the excited spin state of the particular spin system faster than it can relax to its equilibrium population through intrinsic spin-lattice relaxation processes.¹⁴ Our measurements demonstrate that the microwave field B_1 in our cavity is high enough to induce power saturation of all three spin systems, illustrating another advantage of a resonant cavity approach.

In summary, we have shown that our sample probe can be used to perform EDMR in a single-mode microwave cavity at 3.36 T and 94 GHz. Advantages of this technique were demonstrated and discussed by comparing W- and X-band EDMR spectra of accumulation-mode field-effect transistors. This analysis demonstrates that W-band EDMR is a very sensitive technique for the investigation of defect and donor spins in various micro- and nanostructures offering an enhanced sensitivity and a 10 times higher spectral resolution than conventional X-band EDMR.

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